



10th Annual Anti-Tamper Conference

13-15 April 2010

Johns Hopkins University Applied Physics Laboratory, Laurel MD

The Department of Defense Anti-Tamper Executive Agent is please to announce that the 2010 DoD Anti-Tamper (AT) Conference will be held 13-15 April at Johns Hopkins APL, Laurel MD. A security clearance of SECRET is required to attend this event. The theme of this year's conference is:

"Navigating the Technology Transition Gap."

Program Managers, System Engineers, as well as government and industry personnel involved in AT activities will find this event extremely informative. The Conference is a full three day event consisting of presentations on DoD acquisition and AT policy changes, industry technology briefings from industry and government, as well as updates and candid views on current trends in AT protections. Besides senior government and industry speakers, the conference also provides a forum to share ideas and make contacts with leaders and subject matter experts in the AT community.

In an effort to defray ATEA conference costs and improve conference amenities, we will implement a **\$150.00** conference fee this year.

To obtain more details on the conference, please visit our website at <http://at.dod.mil>. Registration will open January 18, 2010 via the web site.

Please join us at Johns Hopkins University in April for the Anti-Tamper Conference. We look forward to seeing you there!